

<b>Notice of References Cited</b>	Application/Control No. 10/635,676	Applicant(s)/Patent Under Reexamination FUKUHARA ET AL.	
	Examiner David S. Blum	Art Unit 2813	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
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	C	US-			
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**FOREIGN PATENT DOCUMENTS**

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Stanley Wolf SILICON PROCESSING FOR THE VSLI ERA Vol. 2 Lattice Press 1990 pages 273-275, 435
	V	John L. Vossen THIN FILM PROCESSES II Acedemi Press1991 pages 178,197,201
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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